

Feasibility of Micro-Multilayer Multifunctional Electrical Insulation (MMEI) System for High Voltage Applications

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Background

Supporting development of Electrified Aircrafts at NASA & Industries

Potential Benefits

 fewer emissions, improved fuel economy, quieter flight, improved efficiency and maneuverability, reduced maintenance costs, and improved reliability

Challenges (Materials)

- High power demand, e.g., 0.5 (9 seat) to 60 MW (300 seat) total propulsive power→ larger currents, thus larger conductors→ huge weight/volume gain
- − High voltage (HV), high frequency (HF) Option, up to 20 40 kV or higher → $\sim 1 \text{ mm thick SOA electrical insulation}$ → still significant weight gain
- Current HV cable technologies, mostly designed for sea-level to low altitude, not suitable for high-altitude airplane operations due to <u>corona PD</u>
- Also, other specs to meet, e.g., up to 4 kHz, 50 500 amps, 180 240 °C+
- → Critical need for lightweight, HV, HF, high temperature, and PD resistant electrical insulation system



Background

- Multilayered structures of thin polymer insulation films, e.g., Kapton PI and PFA or PEEK as bond layer, significantly improved dielectric breakdown voltage (V_B), if wellbonded, regardless of test conditions, Oil vs Air or AC vs DC
 - → Micro-multilayer Multifunctional Electrical Insulation (MMEI) system*



Applications," United States Patent (U.S. Pat.) No. 10,546,666, January 28, 2020

Background

Potential MMEI performance mechanisms

Sequence of representative cross-sectional micrographs of the damage and failure zone



- MMEI structures with higher V_B, typically consisted of thinner individual layers or more # of interfaces, induced a significantly more torturous path for HV current flow through the insulation layers.
- Formation or propagation of damage such as defects/voids in the MMEI structures was effectively suppressed with decreasing the individual layer thickness, typically less than 1 mil/25.4 µm.
- This 3-D DZ analysis confirmed that the size of DZ was directly proportional to V_B in general.

Experimental: Materials

Candidate Materials for MMEI, all commercial products

- Kapton[®] Polyimide (PI) high temperature high dielectric strength films (DuPont)
 - Thermalimide bagging film (KBF) (Airtech), 1, 2, & 5 mil: Thermally stable film
 - HN, 0.3, 1, & 5 mil: A general tough aromatic film, the baseline PI
 - HPP-ST or FPC, 0.5 & 1 mil: Superior dimensional stability and adhesion
 - CRC or CR, 1 mil: Corona resistant nano-composite film
 - HN, 05 & 1 mil, but Si adhesive, 1 & 1.5 mil, backed film
- Perfluoroalkoxy (PFA), 0.5, 1, 2, 5, 10, 20 mil: Semi-crystalline polymer as bond layer
- Polyethylene terephthalate (PET), 2 mil: Semi-crystalline polymer as bond layer
- Polyetheretherketone (PEEK), 0.5, 2, 5 mil: Semi-crystalline/bond layer or Moisture barrier
- Teflon[®] PTFE, 1, 2, 3, 5, 10, 15, 20, 40, 62.5 mil: Moisture barrier
- Flexible Electrical-Insulating Mica (FEIM), 4 mil: Corona barrier

Alternative Candidates:

• CIRLEX[®] Kapton[®] sheet, 10 & 20 mil (Fralock): Proprietary adhesiveless PI laminates, 4 mil to 125 mil + thick

Results & Discussions: Full-scale Demonstrations of MMEI

<u>Developed 1 m long, 3-phase full-scale bus bar prototypes with MERSEN</u> to demonstrate scalability, manufacturability, and commercial applicability

Prototype #1 w/ SOA insulation

Al/Si/14*PTFE/Si/1*CR/Si/14*PTFE /Si/epoxy/5*Mica

- Avg weight of insulation per conductor = 427 gram
- Avg thickness of insulation per side = ~ 0.81 mm (32 mils)





Prototype #2 w/ MMEI insulation

AI cond./1*PFA/[1*PFA/1*HN]₁₀/[1*PFA/1*CR]₂/2*PEEK/0.3*HN

– Avg weight of insulation per conductor = 363 gram \rightarrow <u>~ 15% \downarrow </u>

- Avg thickness of insulation per side = ~ 0.71 mm (28 mils) \rightarrow ~ 12% \downarrow







Results & Discussions: Full-scale Demonstrations of MMEI

Evaluated prototypes by HiPot & PD testing (ASTM D149-20) at MERSEN



- Both passed HiPot breakdown test, >15 kV_{AC}, with leakage current < 0.5 mA.
- PD performance of Prototype #1 > #2, with thick Mica insulation which may not be suitable for power cable due to its rigidity → development of PD resistant MMEI system under way
- acceptable results wrt both manufacturability and performance,
- validated MMEI system for various HV applications including electric aircrafts

Results & Discussions: PD behavior, correlation with LC

PD performance of SOA insulation materials & MMEI with CHPPE OSU



- PDIV = f (t, P) for all material type
- PDIV of PFA, PTFE > others at 1 atm, but all worsened at 100 torr, i.e., challenges for high altitude application
- PDIV = $A^*(LC)^{-B}$ per applied V, independent of material type \rightarrow Practical correlations for material development
- In all cases, PDEV showed almost identical behavior as PDIV but at consistently lower values

Results & Discussions: Development of PD-resistant MMEI

Conductive PFA nanocomposite (PFAn) & Multifunctional-Semiconductive Shield Layers (MSL)



To significantly enhance PD resistance of MMEI for HV applications,

- \checkmark incorporated semiconductive shielding layers \rightarrow PFAn
- \checkmark applied the advantages of multilayering thin insulation materials
- combined various multifunctionalities

 \rightarrow MSL as a subset of MMEI

10 µm

PD-resistant MMEI: Materials

Optimizations of PFAn and MSL via Solution compression-casting with:

- Dyneon[™] 6900GZ aqueous Perfluoroalkoxy (PFA) dispersion (3M, Advanced Materials Division): 50wt% solid, 235 nm average particle size (APS), 7wt% polyether-based emulsifier in distilled water; melting at 310 °C
- Conductive nano-fillers
 - Carbon Black: 1) ACM1333864 (ALFA Chemistry), spherical particles with 150 nm APS; Specific surface area (SSA) >700 m²/g(CB1)
 - Ketjenblack EC600-JD (MSE supplies), electro-conductive, spherical particles with 34 nm APS; BTE SSA = 1270 m²/g (<u>CB2</u>)
 - Graphene Powder (MSE supplies), multi-layer structures with <10 µm APS prepared by thermal exfoliation reduction; SSA = 400-550 m²/g (GP)
- Dispersant for CB dispersion: Marasperse CBOs-4 a highly modified sodium lignosulfonate based dispersant (Borregaard, Norway)

PD-resistant MMEI: Fabrication

Solution compression-casting of MSL, Step-by-step fabrication procedure:

- 1. Dispersed conductive nano-filler(s) into dH_2O with dispersant
- 2. Mixed via ball-milling with Borosilicate beads in Resodyn Acoustic Mixer (LabRAM) followed by an optimized condition
- 3. Mixed both nano-filler dispersion (w/o beads) and PFA dispersion in LabRAM followed by an optimized condition → PFAn dispersion
- 4. Applied thin layer of PFAn dispersion onto clean polymer insulation film, e.g., PEEK with high wettability
- 5. Dried at temperatures below 90°C/194°F
- 6. Stacked PFAn coated polymer films based on predetermined MSL layer configurations
- 7. Compression-casted the stacks at an air-circulated oven preheated to 350°C/662°F for 60 min, or Vacuum-bagged and autoclave processed for large-scale MSL
- * Co-extrusion process to be also considered for industrial-scale manufacturing









Results & Discussions: Development of PD-resistant MMEI

Optimized PFAn compositions and MSL configurations for MSL-MMEI



- Best PFAn composition: 2.5wt% CB2+ 0.5wt% GP+ PFA, and Most effective MSL configuration: [0.5*PEEK/0.5*PFAn]₂, in terms of dispersion characteristics, p up to 300°C, TC, V_B & LC, processibility <u>& layer uniformity/connectivity, inter-layer bonding integrity, and other potential multifunctionalities</u>
- CB2 w/ greater SSA provided much lower electrical percolation threshold than ~20wt% of CB1 for <1,000 Ω ·cm
- Adding GP increased packing density, agglomeration or degree of chain formation in addition to the anticipated thermal stability of semi-conductivity 12

Summary and Conclusions

- The newly developed MMEI system was further optimized and validated:
 - Optimized MMEI structures outperformed most of the SOA insulation materials regardless of test conditions.
 - Potential Mechanisms responsible for MMEI performance were identified experimentally via 3-D dielectric damage and failure mode analyses.
- Scalability, manufacturability, and commercial applicability of MMEI were successfully demonstrated with 1 m long, 3-phase full-scale bus bar prototypes for > 15 kV_{AC}.
- Unique and practical PDIV/PDEV-LC correlations were experimentally determined from various SOA insulation materials and MMEIs for future insulation development.
- Significant progress was made in developing PD-resistant MMEI system via incorporating Multifunctional-Semiconductive Shield Layers (MSL) as a subset of MMEI:
 - Semi-conductive PFA nanocomposite, PFAn, was designed with CB and GP, and their fabrication processes including optimum mixing conditions for uniform/random dispersions were developed
 - Best PFAn composition and Most effective MSL configuration were determined based on systematic processstructure-property relations

Future Work Plan

The following tasks are planned for improvement and implementation of the MMEI system:

- Material-design-process optimizations, especially for additional multifunctionalities such as EMI shielding, thermal management, or mechanicals, and development of new/modified constituent materials with improved performance
- More extensive, systematic performance evaluations of the MSL-MMEI structures/prototypes including (i) thermal-mechanical-physical performance characterizations including interlayer bonding integrity and (ii) synergistic durability assessment
- Continuation of scale up, prototype development of power cables, manufacturability assessment, and commercialization

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